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Introduction

Transistors serve as fundamental components in von Neumann computers, acting as versatile electronic building blocks. Transistors primarily operate as switches, while also possessing the amplification capability for electric currents. This functionality enables them to either facilitate or impede the flow of current, thereby establishing a binary state for each transistor-akin to the representation of 1 or 0. In our brain, electrical signals exhibit more complexity than a simple binary code since synaptic connections embody various "weights" or strengths.^{1,2} Several synaptic devices have been built to imitate this, which has spurred the emergence of neuromorphic computers. These computers employ chip architectures that combine memory and processing within a single unit. This solution addresses the von Neumann architecture bottleneck and enables these systems to execute computations efficiently while consuming minimal power. Neuromorphic computers pave the way for novel approaches to computation that align with the parallel and distributed nature of biological neural networks.3,4

Exploring response time and synaptic plasticity in P3HT ion-gated transistors for neuromorphic computing: impact of P3HT molecular weight and film thickness†

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Neuromorphic computers, inspired by the brain's neural networks, hold promise for efficient computation. Ion-gated transistors (IGTs), which employ ionic gating media, are particularly attractive for use in neuromorphic computing with remarkably low power consumption. This study focuses on IGTs utilizing organic polymer films of poly (3-hexylthiophene) (P3HT) as synaptic elements. The impact of P3HT molecular weight (MW, i.e. 24 kDa, 42 kDa, 92 kDa) and P3HT film thickness on IGT response time and synaptic behavior is investigated. Various synaptic behaviors are emulated, including paired-pulse facilitation (PPF) and spike number-dependent plasticity (SNDP). Additionally, the transition from short-term plasticity (STP) to long-term plasticity (LTP) is achieved by tuning MW, channel thickness, and gate-source voltage (V_{gs}) pulse parameters. These findings pave the way for P3HT-based IGTs as advanced artificial synaptic elements for neuromorphic computing. PAPER
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Synaptic elements in neuromorphic structures have not yet fully harnessed the extensive functionality and dynamic nature observed in biological synapses.^{$5-7$} This functionality, known as "synaptic plasticity", plays a critical role in neurons transmitting signals, memory, filtering, learning, and various other brain functions. $8-10$ Therefore, it is crucial to create and produce biorealistic synaptic components that demonstrate strong functionality and display complex temporal and spatial dynamics.¹¹ The quest for a biorealistic artificial synapse that possesses excellent linearity, symmetry, collocated processing and memory capabilities, and low power requirements remains unresolved.¹²

To replicate these functions within a neuromorphic computer, extensive efforts have been directed toward the development of various devices. Among these devices, synaptic transistors based on organic films stand out as transistors functional for this purpose. $13-15$ The structural properties of the organic films significantly influence its conductance and consequently, the output signal.¹⁶

By applying a voltage across the transistor, the organic film undergoes modifications that give rise to either depression or potentiation of the electric signal. This phenomenon closely resembles the activity spikes observed in the brain. Consequently, these changes can trigger a form of plasticity, wherein numerical information becomes encoded within the spikes. Parameters such as spike frequency, timing, magnitude, and shape contribute to this

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encoding process. The conversion between binary values and spikes, and vice versa, remains an ongoing and dynamic field of research, with active investigations aimed at refining the precise methodologies involved in this conversion process.¹⁷

Synaptic ion-gated transistors (IGTs) use ionic media to induce high carrier concentrations in the channel material, at low voltages. IGTs can emulate short-term and long-term plasticity, with low power consumption.

The ion gating effect is due to the redistribution of ions in the proximity of/within the channel. When a gate-source voltage (V_{gs}) is applied, initially ions from the ionic medium accumulate at the surface of the semiconducting channel, resulting in electrostatic doping (two-dimensional, 2D, doping).18–²¹ The possibility of ion penetration in the semiconducting channel material of IGTs is key to threedimensional (3D) electrochemical doping. When ions can easily diffuse back into the ionic medium upon removal of V_{gs} , short-term plasticity (STP) occurs. Conversely, when ions are deeply intercalated within the channel material, they are not easily released after removing V_{gs} , leading to the emergence of long-term plasticity (LTP). In other words, the time scale of the synaptic activity is determined by the quality of ion incorporation, two or three-dimensional. $22,23$ RSC Applied interfaces

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By changing the input $V_{\rm gs}$ pulse parameters, such as duration, number, amplitude, and frequency, in addition to the structure and thickness of the transistor channel material, it is possible to modulate several synaptic functions through a two-step ion gating process and subsequent ion diffusive dynamics.

Synaptic IGTs exhibit advanced functionalities such as paired-pulse facilitation (PPF), spiking rate-dependent plasticity (SRDP), and dynamic filtering. These functionalities have highlighted the synaptic transistors' potential for the development of neuromorphic systems.²⁴

In IGTs, the application of a V_{gs} pulse leads to an initial increase in I_{ds} (drain-source current), which then gradually returns to its original state. This decay time, known as the response time (τ) , is an important factor in the modulation of synaptic plasticity in IGTs. Indeed, τ shares similarities with the decay of the excitatory postsynaptic current (EPSC) observed in biological synapses.^{25,26} The value of τ can be determined by calculating the time constant of the fitted exponential to the decay of I_{ds} with time, following the removal of the $V_{\rm gs}$ pulse.²⁷

Regioregular poly-3-hexylthiophene (RR P3HT) is a wellstudied semiconducting polymer in organic electronics due to its high charge carrier mobility ranging from 10^{-5} to 10^{-1} $\text{cm}^2 \text{ V}^{-1} \text{ s}^{-1}$ and commercial availability.²⁸⁻³⁴

The molecular weight (MW) of P3HT affects the morphology and structure of corresponding films. Atomic Force Microscopy (AFM) and X-ray Diffraction (XRD) have been employed to shed light on such effect. AFM images show that films of P3HT with very low MW (ca. 5 kDa) have a rod-like structure whereas films of P3HT with intermediate MW (ca. 50 kDa) feature less ordered, isotropic nodule structure.³⁴ Complex chain entanglement in high MW P3HT leads to extended amorphous regions in corresponding films.35–³⁸ This notion has been further validated by XRD measurements.34,39 Researchers have also explored structural and orientational changes in P3HT films along the film thickness using high-resolution Grazing Incidence X-ray Scattering (GIXS).

For P3HT films grown on $SiO₂$ substrates, small crystallite size and less oriented crystallites were observed at the P3HT/ $SiO₂$ interface, with the overall degree of crystallinity found to increase with the increase of the film thickness $(i.e.$ distance from the substrate surface). $40-43$

A detailed study of P3HT films with different MWs and thicknesses is crucial to establish structure/response relationships for their application in neuromorphic computing. Different MWs and thicknesses are expected to modify the molecular packing, orientation of the thiophene rings, degree of order, and nanoscale morphology of P3HT thin film. These factors are intimately tied to the ion permeability and charge carrier transport properties, thereby modulating the P3HT-based IGTs response time and synaptic behaviors.

Previous research on IGTs has reported τ ranging from microseconds to a few tens of milliseconds, depending on the specific device structure and operating conditions.⁴⁴⁻⁴⁶ In this work, we report on the response time and synaptic behavior of IGTs based on spin-coated P3HT films as channel material with different MWs, i.e. low (24 kDa), intermediate (42 kDa), and high (92 kDa), and thickness (obtained by changing the spin coating speed from 500 rpm to 4000 rpm). The ionic medium was the ionic liquid 1-ethyl-3 methylimidazolium bis(trifluoromethylsulfonyl) imide, [EMIM][TFSI] (Fig. 1a). After conducting transistor electrical characterizations, we studied various synaptic behaviors of bio-inspired synaptic [EMIM][TFSI]-gated P3HT transistors, such as response time, STP-to-LTP transition, spike numberdependent plasticity (SNDP) and pair-pulse facilitation (PPF) as a function of the MW, thickness, V_{gs} pulses parameters, and drain-source voltage (V_{ds}) .

Results and discussion

To study the effect of MW and thickness of P3HT thin films on the response time and synaptic behavior of IGTs, we spin coated P3HT films on $SiO₂/Si$ using different P3HT MWs (namely low (24 kDa), intermediate (42 kDa), and high (92 kDa)), different spin coating times from 20 to 40 s and different rotation speeds (500 rpm, 1000 rpm, 2000 rpm, 4000 rpm). We observe a difference in thickness among various MWs P3HT films and spin coating times (Fig. 1b).

Increasing the spin-coating speed, we observe a decrease of the P3HT film thickness (Fig. 1c). AFM images of P3HT films (Fig. 1d–f) reveal that the root mean square (rms) roughness of the surface decreases with an increase in the molecular weight (MW) of P3HT, *i.e.* 2.2 \pm 0.6 nm for low MW, 0.8 ± 0.1 nm for intermediate MW, and 0.60 ± 0.03 nm for high MW P3HT, for a spin-coating time of 30 s at 1000

Fig. 1 a) P3HT-based IGT device structure. Thickness of P3HT films deposited with: b) different MWs at five spin coating times (20, 25, 30, 35, and 40 s, at 1000 rpm), c) different spin coating speeds (lines are fittings) at 30 s and with MW 50–70 kDa. AFM images of P3HT films, spin coated during 30 s on SiO₂/Si, at 1000 rpm, d) low MW e) intermediate MW f) high MW. Image size is 5 μ m × 5 μ m.

Fig. 2 Transfer characteristics (black line) in the linear regime (V_{ds} = −0.2 V, (3 cycles)) at V_{gs} scan rate 50 m V s^{−1} (inset: output characteristic with V_{gs} = 0, −0.2, −0.4, −0.6, −0.8, −1 V at V_{ds} 50 m V s⁻¹ scan rate) and transconductance curve (red line) for [EMIM][TFSI]-gated transistors based on a) high MW b) intermediate MW c) low MW P3HT deposited at 1000 rpm during 30 s. d) Transient response of an [EMIM] [TFSI]-gated P3HT transistor with high, intermediate, and low MW for $V_{gs} = -1$, -0.8, and -0.5 V at different V_{ds} . The duration time of the V_{gs} bias is 200 ms.

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rpm. In other words, the increase in the P3HT molecular weight is associated with an increase in the smoothness of the film surface, most likely due to an increase in the shortrange order within the molecular weight.³⁵⁻³⁸

A. Effect of different P3HT MWs on response time and synaptic behavior of P3HT IGTs

A.1. Transfer and output characteristics of [EMIM][TFSI] gated P3HT IGTs. Transfer and output characteristics show a typical p-type behavior of devices working in accumulation mode. I_{ds} increases with the decrease of V_{gs} scan rate from 100 to 25 m V s^{-1} due to the increased time available to accommodate the redistribution of the ions (Fig. S1 and S2†). Further, I_{ds} increases with the decrease of MW (Fig. 2a–c) and the increase of the channel thickness (as determined by the spin coating conditions) (Fig. 4a–d and 1c).

Devices fabricated using high MW P3HT exhibit a higher transconductance $(g_m = \delta I_{ds}/\delta V_{gs}$, a transistor parameter that describes how I_{ds} responds to variations in V_{gs} (ref. 18 and 47)) than for low MW counterparts, attributable to higher ionic permeability.^{37,48,49} The increased transconductance implies that even a slight change in V_{gs} can result in a substantial variation in I_{ds} , rendering high-MW P3HT IGTs more sensitive to changes in V_{gs} compared to lower MWs counterparts.

A.2. Effect of V_{gs} and V_{ds} amplitudes on P3HT IGT response time, for different P3HT MWs. We studied the excitatory postsynaptic current (EPSC) response upon applying a 200 ms

square step V_{gs} pulse with amplitudes of −0.5, −0.8, and −1 V, at V_{ds} = −0.2, −0.6, −0.8, and −1 V (Fig. 2d). Low amplitude V_{gs} presynaptic pulses are expected to dope regions in the P3HT films close to the film's surface and/or featuring short-range order (amorphous).35 These regions can rapidly de-dope, resulting in the rapid decay of the postsynaptic current (PSC). This response is analogous to STP. We notice that τ increases with the increase of V_{gs} for all P3HT MWs considered. Higher values of V_{gs} are expected to induce a deeper ion penetration in the films. This implies longer times for ions' removal prior to reaching the steady state, after the removal of V_{gs} (LTP). Further, in agreement with Bernards' model, 47 we observed that the increase of V_{ds} causes the decrease of τ . RSC Applied interfaces

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The response time increases with decreasing MW of P3HT, for V_{gs} = −0.5, −0.8, and −1 V (Fig. 2d). For instance, for presynaptic spikes with 200 ms pulse width, $V_{gs} = -1$ V and $V_{ds} =$ -0.2 , τ increases from 22.3 to 39.5 ms, *i.e.* by 77%, with decreasing MW. The increase of MW brings about an increase in the entanglement of the P3HT chains, paralleled by an increase in the short-range ordered portion of the films. $37,38,48$ This is expected to promote ion permeability, *i.e.*, facilitate P3HT doping/de-doping.

A.3. Impact of different MWs on IGT synaptic behaviors. Paired pulse facilitation (PPF) is the rate of enhancement in the EPSC amplitude after the second of two repetitive excitatory postsynaptic potentials (EPSPs). In PPF, two EPSC peaks $(A_1 \text{ and } B_2)$ A_2) are triggered, with the latter larger than the former, with PPF = $(A_2 - A_1)/A_1 \times 100\%$. In our experiments, we used V_{gs} = -1 V, V_{ds} = -0.6 V, with an interval Δt (Fig. 3a). Fig. 3b shows PPF as

Fig. 3 Synaptic behavior of artificial synapses based on P3HT IGTs for different P3HT MWs. a) I_{ds} triggered by a pair of successive presynaptic V_{gs} (-1 V) pulses with a pulse interval Δt . A₁ and A₂ are the amplitudes of I_{ds}. b) PPF index as a function of pulse interval of two consecutive V_{gs} pulses, Δt = 10 ms to 2 s. c) Response time of second I_{ds} pulses after applying two consecutive V_{gs} pulses versus time interval of pulses, Δt . d) Response time of P3HT IGT versus different numbers of V_{gs} square step train pulses, from 5 to 120 pulses. V_{gs} = −1 V and V_{ds} = −0.6 V. e) SNDP index as a function of the. number of V_{qs} pulses. f) Response time of IGT versus V_{qs} pulse duration for low and high MW P3HT.

a function of Δt and P3HT MW. The highest PPF value is observed at $\Delta t = 10$ ms. With Δt increasing gradually, the PPF index value decreases rapidly. The mechanism governing the PPF process can be explained as follows. During the first V_{gs} spike, TFSI anions move towards the surface of the P3HT films; a fraction of these anions move beneath the film surface, within film depth. When the second V_{gs} spike is applied, shortly after the first one $(\Delta t < 100 \text{ ms})$, the movement of the anions triggered by the first V_{gs} spike is still partially present such that the effects of A_1 and A_2 sum up. Consequently, the magnitude of A_2 EPSC is larger than that of A_1 . For $\Delta t > 100$ ms, anions have the time to reach the equilibrium state to the extent that the summation effect disappears.

Increasing the degree of order (i.e. increasing the roughness) in the semiconducting channel by decreasing the P3HT MW brings about limited ion permeability over an extended lapse of time. A higher quantity of ions contributes to an elevated PPF index (Fig. 3b). The summation effect causes an increase in the IGT response time (Fig. 3c).

A.4. IGT response time as influenced by the number of V_{gs} pulses and P3HT MW. In order to investigate the synaptic properties of [EMIM][TFSI]-gated P3HT transistors, we applied a series of V_{gs} pulses (5, 10, 20, 40, 60, 80, 100, 120 pulses). We observed a transition in the device behavior from short-term plasticity (STP) to long-term plasticity (LTP) with increasing number of pulses. Such transition is commonly regarded as the foundation for learning and memory in the human brain. We replicate LTP in P3HT IGTs by applying a series of consecutive V_{gs} pulses (−1 V, 200 ms) with a 200 ms interval while maintaining $V_{ds} = -0.6$. This sequence of V_{gs} pulses effectively facilitates the permeation of ions in the P3HT films bringing about an increase in I_{ds} associated with the modulation of the channel conductivity. Factors such as the increase of the P3HT MW, with an associated increase of the amorphous portion of the channel material and channel permeability, play a role. SNDP_{1−n} = $(A_n - A_1)/A_1 \times 100\%$ (SNDP index) increases as the number of pulses increases (ranging from 5 to 120, Fig. 3e). For low MW P3HT, the SNDP index for $n = 120$ is about 30% while for high MW P3HT, it is 15%. This finding indicates that the transition from STP to LTP in low MW P3HT-IGTs is twice that of high MW P3HT-IGTs.

With the increase of n , there is an increase in ion redistribution time, paralleled by an increase of τ. We observed a significant impact of P3HT MW on the IGT response time when a low number of pulses was applied. However, as the number of pulses increased, τ of different P3HT MWs became nearly identical (Fig. 3d).

A.5. Impact of MW and pulse duration on IGT response time. A longer pulse duration provides more time for ions to

Fig. 4 Transfer characteristics in the linear regime (V_{ds} = −0.2 V (3 cycles)) at V_{gs} 50 m V s⁻¹ scan rate (inset: output characteristic with V_{gs} = 0, −0.2, −0.4, −0.6, −0.8, −1 V and V_{ds} 50 m V s⁻¹ scan rate) and transconductance curve for [EMIM][TFSI]-gated P3HT transistors prepared with spin coating rate: a) 500 rpm b) 1000 rpm c) 2000 rpm d) 4000 rpm, on 30 seconds with intermediate MW. e) Transient response of [EMIM][TFSI] gated P3HT transistors with intermediate MW with V_{gs} = −1.2, −1, −0.8, and −0.5 V, at different V_{ds}. The duration of the V_{gs} bias is 200 ms.

penetrate the channel, resulting in an extended de-doping time. Consequently, upon V_{gs} removal, τ increases. For pulse durations lower than 1 s, decreasing the MW of P3HT causes higher values of τ ; for durations longer than 1 s, τ is similar for high and low MW P3HT IGTs (Fig. 3f).

B. Impact of film thickness (as controlled by spin coating conditions) on response time and synaptic behavior in P3HT IGTs

IGT transfer ($V_{\rm gs}$ scan rate 100, 50 and 25 m V s^{−1}, and $V_{\rm ds}$ = −0.2 V) and output characteristics (V_{ds} scan rate 100, 50 and 25 m V s⁻¹, and V_{gs} = 0 to -1 V) show that I_{ds} decreases with the increase of the spin coating speed (thinner P3HT film) (Fig. 4a–d, S2a-l† and 1c). The higher permeability of thinner P3HT channels due to the lower degree of order brings about higher transconductance, *i.e.* an enhanced IGT sensitivity to changes in $V_{\rm gs}$.^{34,40,48,49}

We investigated the response time of P3HT IGTs by employing a square V_{gs} pulse with a width of 200 ms and varied amplitudes of -0.5 , -0.8 , -1 , and -1.2 V. The measurements were performed at different V_{ds} of -0.2, -0.6, −8, and −1 V (Fig. 4e). Additionally, we examined the impact of different channel thicknesses (as determined by the spin coating rates used for P3HT films' deposition) on τ . The increase of τ with the increase of $V_{\rm gs}$ and the decrease of τ with the increase of V_{ds} are clear for all spin coating speeds. Further, τ increases with the decrease of the spin coating speed from 4000 to 500 rpm (Fig. 4e). The increased order RSC Applied interfaces

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of P3HT obtained by decreasing spin coating speed decreases the permeability of ions into the channel and increases the ion redistribution time or IGT response time. We can also explain the observed result through the Bernards' model.²⁷

Fig. 5a shows increasing film thickness can enhance the pair pulse facilitation. Slow ion diffusion in a thick channel affects pair pulse facilitation, possibly leading to longer facilitation times (Fig. 5b). With thick films, the channel can store more charge upon the first pulse, leading to more pronounced facilitation during the second pulse.

Fig. 5c and d show that the increase of the V_{gs} pulse duration time and number of pulses can have the same effect on the synaptic behavior of P3HT IGTs with different channel thicknesses (obtained by controlling the spin coating conditions as detailed in Fig. 1c). By increasing the number of pulses and V_{gs} pulse duration, we can increase τ , which can be interpreted as the redistribution time of the ions, upon $V_{\rm gs}$ removal. Increasing the thickness (going from a spin coating speed of 4000 rpm to 500 rpm, Fig. 1c) results in an increase in τ for all V_{gs} pulse duration times and pulse numbers (Fig. 5c and d).

Further, we can observe a stronger transition from STP to LTP, in a thicker P3HT film. We observed that $SNDP_{1-120}$ (where SNDP_{1−n} = $(A_n - A_1)/A_1 \times 100\%$) is 48% for thick channel films (500 rpm) and 11% for thin films (4000 rpm). These values quantitatively describe the evolution of the SNDP index with the thickness of the P3HT films (Fig. 5e and 1e).

Fig. 5 Synaptic behavior of artificial synapses based on P3HT IGTs for films spin coated at different speeds (in turn associated with thicknesses, Fig. 1c). a) PPF index as a function of pulse interval of two consecutive V_{gs} pulses (Δt from 10 ms to 2 s). b) Response time of second I_{ds} pulses after applying two consecutive V_{gs} pulses versus time interval of pulses (Δt). c) Response time of IGTs versus V_{gs} pulse duration. d) Response time of P3HT IGTs versus different numbers of V_{gs} square step train pulses, from 5 to 120 pulses. V_{gs} = −1 V and V_{ds} = −0.6 V. e) SNDP index ((A_n − A₁)/A₁ \times 100%), with $n =$ the number of V_{gs} pulses, as a function of the number of V_{gs} pulses.

A. Microfabrication

Photolithography for electrode patterning was performed on 200 ± 10 nm-thick $SiO₂$ on 525 ± 25 µm-thick doped silicon wafer purchased from WaferPro, San Jose, California. Au/Ti electrodes (40 nm/5 nm) had a width (W) of 4 mm and an interelectrode distance (L) of 10 μ m. The patterned substrates were cleaned with a sequential ultrasonic bath in isopropanol alcohol (IPA) for 10 min, acetone for 10 min and IPA for 10 min, prior to the deposition of the P3HT thin films.

B. P3HT films deposition

P3HT solutions consisting of 10 mg regioregular P3HT (RIEKE Metals) with different molecular weights, low (24 kDa), intermediate (42 kDa), and high (92 kDa), in 1 ml chlorobenzene were stirred overnight in an N_2 glove box (O_2) $<$ 5 ppm, H₂O $<$ 5 ppm). P3HT films were deposited by 30 seconds spin coating at 1000 rpm on the $SiO₂/Si$ substrates. In order to control the thickness of the films, P3HT with MW 50–70 kDa were spin coated for 30 seconds at various rotation speeds: 500, 1000, 2000, and 4000 rpm. All devices were thermally treated on a hotplate at 100 °C for 2 h in the N_2 glovebox. The ionic liquid used as the gating medium, [EMIM][TFSI], purchased from IoLiTec (>99%), was purified under vacuum (ca. 10^{-5} Torr) for 24 h at 60 °C before use. [EMIM][TFSI] was dropped onto the Durapore® membrane (4 mm \times 9 mm-sized, 125 μ m-thick). The membrane was positioned in correspondence with the transistor channel. Large surface area carbon paper (Spectracarb 2050, 170 μmthick), coated with an ink comprising activated carbon (PICACTIF SUPERCAP BP10, Pica, 28 mg ml−¹) and polyvinylidene fluoride (PVDF, KYNAR HSV900, 1.4 mg ml⁻¹) binder in N-methyl pyrrolidone (NMP, Fluka) was utilized as the gate electrode (6 mm \times 3 mm-sized). **Paper**
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C. Characterization of the channel material

The thickness of P3HT thin films were measured by Dektak 150 profilometer. To obtain the thin film height, the probe physically moved along the surface during the measurement. The topography of the samples was probed by atomic force microscopy (AFM), in ambient conditions, with an NT-MDT NTEGRA II microscope. The images were acquired in semicontact (tapping) mode with an NSG10 cantilever (a length of 95 um, a width of 30 um, resonant frequency of 240 kHz and force constant of 11.8 N m^{-1}).

D. Electrical characterization of the devices

Transistor characterization was conducted using a semiconductor parameter analyzer, Agilent B1500A, and a house-made micromanipulated electrical probe station inside the N_2 glove box.

Conclusions

In conclusion, we conducted a comprehensive study of the properties and performance of synaptic P3HT ion-gated transistors (IGTs). We examined the effect of P3HT molecular weight (MW) on morphology, transistor device characteristics, response time, and synaptic behavior of IGTs fabricated with low (24 kDa), intermediate (42 kDa), and high (92 kDa) MW. Low MW P3HT films, exhibiting a higher degree of order, expected to be associated to lower ion permeability with respect to intermediate and high MW P3HT films, bringing about corresponding devices with lower transconductance. Further, low MW P3HT IGTs exhibit longer response times upon application of $V_{\rm gs}$ pulses concerning counterparts making use of intermediate and high MW.

We emulated several essential synaptic functions, including PPF and SNDP, and realized a transition from STP to LTP by tuning V_{gs} pulses' parameters, such as amplitude, duration, and pulses' number, in low, intermediate, and high MW P3HT-IGTs. In all cases, devices with low MW P3HT have more effective STP-to-LTP transition than medium and high MW counterparts.

The study of the dependence of response time and synaptic behavior on film thickness in P3HT-based IGTs revealed that films deposited with lower spin coating speeds (thicker films, more ordered films) feature lower transconductance. Our study demonstrates a significant increase in the response time of IGTs with an increasing thickness of the P3HT film. Moreover, increasing film thickness brings about an improvement in synaptic behavior, encompassing PPF and SNDP. The transition from STP to LTP is achieved by controlling the thickness of the films. Thicker P3HT films bring about higher levels of LTP.

In perspective, we plan to explore the development of organic synaptic phototransistors exposed to light pulses, to finely tune and modulate synaptic behaviors.

Author contributions

R. K. A. and C. S. designed the experiments. R. K. A. and Z. G. performed the transistor and time-resolved characterizations. R. K. A and A. C. performed AFM experiments. R. K. A., Z. G. and C. S. drafted the manuscript. All authors commented on the manuscript.

Conflicts of interest

There are no conflicts to declare.

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